



www.afm-iournal.de

# **Rapid Prototyping for Soft-Matter Electronics**

Tong Lu, Lauren Finkenauer, James Wissman, and Carmel Majidi\*

A series of rapid and inexpensive methods to produce elastically soft sensors and circuits in minutes using a CO $_2$  laser (10.6  $\mu m$  wavelength) are introduced. These soft-matter electronics are composed of laser-patterned films of conductive poly(dimethylsiloxane) (cPDMS) and liquid-phase gallium–indium (GaIn) alloy embedded in a thin sheet of soft silicone elastomer. Direct laser patterning eliminates the need for photolithography, replica molding, and customized inkjet or microcontact ( $\mu CP$ ) printing, and allows conductive traces of cPDMS and liquid GaIn to be rapidly integrated into a single soft-matter circuit. The versatility of this fabrication method is demonstrated by the production of a variety of electrically functional soft-matter sensors and circuit elements that contain features with >150  $\mu m$  planar dimensions. It is postulated that, in the case of GaIn alloy, patterning occurs when the recoil force of the escaping vapor exceeds the liquid's surface tension. This mechanism exploits the unique "moldability" of liquid GaIn alloy, which forms a surface oxide of Ga2O3 that allows the patterned film to maintain its shape.

### 1. Introduction

Soft-matter electronics are composed of electrically conductive fluids, pastes, gels, and elastomers embedded in a thin film of elastically soft material.[1-6] In contrast to conventional electronics, these devices contain no rigid materials and remain electrically functional when stretched to several times their natural length. In this respect, soft-matter electronics complement other stretchable circuit technologies based on carbon nanotubes, [7,8] graphene, [9] and wavy circuit wiring. [10,11] In recent years, stretchable electronics have been produced by embedding a thin film of soft silicone elastomer with microfluidic channels of liquid-phase gallium-indium alloy. Liquid GaIn has 1/20<sup>th</sup> the conductivity of copper wiring and remains intact as the surrounding elastomer is stretched. Liquid GaIn alloys such as EGaIn (eutectic gallium-indium) and Galinstan (gallium-indium-tin) have been used as highly stretchable electrical wiring, [12,13] elastically tunable antennae for wireless communication, [14-16] logic gates and diodes for elastically soft digital circuits,[17,18] and hyperelastic sensors for measuring pressure, [19,20] strain, [21] friction, [22,23] and bending curvature. [24]

Because of their intrinsic elasticity, soft-matter electronics have a potentially central role in applications like

T. Lu, L. Finkenauer, J. Wissman, Prof. C. Majidi Soft Machines Lab Department of Mechanical Engineering Carnegie Mellon University Pittsburgh, PA 15213, USA

Pittsburgh, PA 15213, USA E-mail: cmajidi@andrew.cmu.edu

DOI: 10.1002/adfm.201303732



wearable computing and medical robotics that depend on mechanical impedence matching with natural human tissue. However, progress in these application domains requires more versatile methods to simultaneously pattern thin films of conductive elastomer and liquid GaIn for rapid integration into circuits and sensor arrays. For example, poly(dimethylsiloxane) (PDMS) filled with carbon nanotubes or other conductive microparticles (cPDMS) such as nickel or silver may be patterned through replica molding<sup>[25,26]</sup> or microcontact printing.<sup>[27]</sup> In the case of liquid GaIn alloys, patterning is currently performed with needle injection, inkjet printing,<sup>[28]</sup> masked deposition,<sup>[29]</sup> and microcontact printing (µCP).[30] While reliable, these existing methods typically require photolithography or customized printing hardware

and can be costly and time consuming. An exception is the method presented in [26] in which a commercial excimer laser (wavelength,  $\lambda=248$  nm) is used to produce molds for casting cPDMS. Another approach is stencil lithography, which has been recently applied to liquid GaIn.[22,31,32] However, although it is rapid and inexpensive, stencil lithography can only be used to produce a limited range of circuit geometries.

In this manuscript, we introduce a method for producing soft-matter electronic circuits by patterning thin films of cPDMS and liquid-phase EGaIn alloy with a CO2 laser (10.6 µm wavelength). This rapid prototyping approach to fabrication eliminates the need for photolithography or customized printing hardware. Moreover, we demonstrate the ability to laser-pattern EGaIn through a mechanism that exploits the unique "moldability" of the liquid alloy. Figure 1 presents examples of how CO<sub>2</sub> laser patterning is used to produce soft-matter sensors for electronic skin applications. These include a fingertip mounted carbon-based cPDMS sensor for detecting skin contact (Figure 1a), a miniaturized multi-layered carbon-based cPDMS sensor array (Figure 1b), and inclusions of PEDOT:PSS embedded in PDMS (Figure 1c) and urethane (Figure 1d). The test patterns in Figure 1e are produced by using the CO2 laser to pattern a thin layer of EGaIn alloy sandwiched between two layers of PDMS. After the excess EGaIn and elastomer are removed, the patterned film is sealed in additional PDMS. Figures 1f,g present an integrated circuits composed of serpentine EGaIn wires and cPDMS pads for mounting an LED and connecting to an external power supply.

CO<sub>2</sub> laser ablation has been previously used to produce microfluidic channels in PMMA<sup>[33]</sup> and PDMS.<sup>[34]</sup> Polymers are typically patterned through a combination of vaporization and

www.MaterialsViews.com

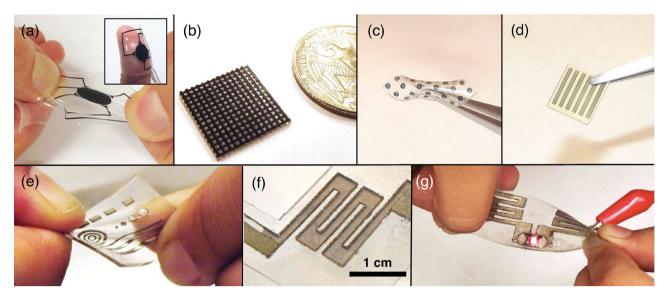


Figure 1. a) Resistive tactile sensor composed of laser-patterned conductive poly(dimethylsiloxane) (cPDMS). b) Sensor array composed of overlapping strips of cPDMS insulated by non-conductive elastomer. c) Laser-patterned inclusions of PEDOT:PSS embedded in PDMS. d) Laser-patterned PEDOT:PSS embedded in polyurethane. e) Laser-patterned eutectic Gallium-Indium alloy (EGaIn) embedded in PDMS. f) Integration of a serpentine EGaIn wire and cPDMS electrodes in a PDMS-sealed circuit. g) LED-embedded circuit composed of laser-patterned cPDMS and EGaIn.

the displacement of molten polymer. Molten polymer is displaced when the pressure of the escaping vapor (recoil force) exceeds the surface tension of the liquid. We postulate that thin films of PDMS filled with conductive microparticles can be similarly patterned with a CO2 laser. This includes carbonbased cPDMS, such as PDMS filled with acetylene carbon black, and PDMS filled with silver and nickel microparticles.

In contrast to elastomers, liquid-phase GaIn metal alloys cannot be ablated with a CO<sub>2</sub> laser. As with other metals, EGaIn would require a high-energy UV radiation source for photochemical ablation. Instead, we postulate that EGaIn is removed with the same liquid metal expulsion mechanisms used in CO<sub>2</sub> laser beam welding (LBW).[35] However, whereas stainless steel, titanium, and other solid metals require a high power to initiate melting (>1 kW for CO2 lasers), GaIn alloys are already molten at room temperature and, as with molten polymer, can be displaced by pressure from the vapor escaping the PDMS beneath. In addition to being in a liquid state, GaIn alloys form a surface oxide of Ga<sub>2</sub>O<sub>3</sub> that prevents the liquid from flowing back into the laser-patterned region. In other words, this property of "moldability" enabled by the oxide skin<sup>[36-39]</sup> allows the liquid to retain its shape after it has been patterned. Since they have both low fluidic viscosity and a high surface tension, GaIn alloys can simultaneously behave like a solid and a liquid at sub-millimeter length scales. This unique combination of properties enables the rare ability to pattern a metal alloy with an inexpensive laser engraving system that operates at relatively high wavelengths (10.6  $\mu m)$  and low power (1–30 W).

#### 2. Results

We use a 30 W CO<sub>2</sub> laser (VLS 3.50; Universal Laser Systems, Inc.) to pattern thin films of electrically conductive cPDMS and EGaIn and produce elastic, soft sensors and circuit elements. The methods for patterning cPDMS and a multi-layered circuit are presented in Figure 2a. As discussed in the Experimental Section below, carbon-based cPDMS is composed of 84 wt% 20:1 PDMS (Sylgard 184; Dow Corning, Inc.) mixed with 16 wt% acetylene carbon black powder (Alfa Aesar). We have also patterned films of cPDMS containing either 84% silver microparticles (2-3.5 µm; Sigma Aldrich, Inc.) or a combination of 65% nickel and 25% silver (NuSil R-2637; NuSil Technology LLC). First, a thin film of cPDMS is applied by spin coating the uncured elastomer on a brass sheet and laser-patterning it after curing (i), followed by removal of the excess cPDMS (ii). The brass sheet is finally coated with a sealing layer of non-conductive PDMS before peeling the cured film from the brass cutting surface (iii). For this sequence of steps, which was used to produce the tactile sensor in Figure 1a, the embedded cPDMS circuit is exposed and flush with the surrounding PDMS. However, to produce multi-layered circuits, such as the sensor array in Figure 1b, additional layers of conductive and non-conductive PDMS must be added. For a multilayered circuit, the "bottom" layer is patterned and sealed as before (i-iii). After removal of this sheet, the cutting surface is coated with a new layer of cPDMS and subsequently PDMS after curing (iv). The two layers are then patterned with the laser (v) before a final coating of PDMS (vi) and removal of excess material (vii). The uncured PDMS deposited after patterning the two sheets (vi) acts as an adhesive film for bonding the "top" layer with the previously fabricated bottom layer (viii). Lastly, the completely cured multi-layered circuit is peeled from the cutting surface (ix).

Figures 3b,c demonstrate CO2 laser machining of single and double-layers of cPDMS with laser powers of 0.6 and 1.2 W, respectively. For a single layer of cPDMS, a minimum line-toline spacing of 260 µm is possible (Figure 3c). This maximum resolution is limited by the laser spot size and pulse rate. Smaller feature sizes can be achieved by a lower wavelength

www.afm-journal.de

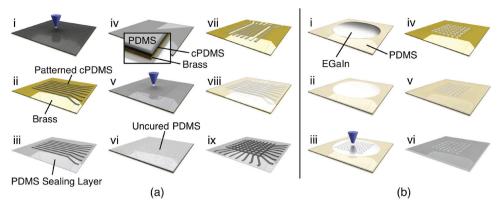
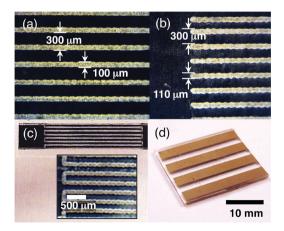


Figure 2. a) Fabrication steps for a resistive tactile sensor composed of a multiple layers of laser-patterned cPDMS. b) Fabrication steps for laser-patterned EGaIn.

laser with a smaller beam diameter and higher pulse rate to prevent heating and melting of the surrounding material. The samples presented in Figures 3a–c are produced with carbon-based cPDMS although this same technique can also be used to pattern silver/nickel- (Figure 1f) and silver-based (Figure 3d) cPDMS. Because of their higher viscosity, thin layers of these metal-based conductive elastomers may be prepared with a thin film applicator (ZUA 2000; Zehntner Testing Instruments) instead of spin coating. As demonstrated in Figure 4, a  $\rm CO_2$  laser can also be used to pattern poly(3,4 ethylenedioxythiophene) poly(styrenesulfonate) (PEDOT:PSS; Sigma Aldrich, Inc.) and embed it in either PDMS (Figure 4a) or soft polyure-thane (Ure-Bond II; Smooth-On, Inc.) (Figures 4b,c).

This films of liquid EGaIn alloy are patterned using the steps presented in Figure 2b. We begin by spin coating a layer of PDMS on a brass cutting sheet. Next, we use an elastomeric roller to deposit a  $10-20~\mu m$  thin layer of EGaIn (i); a minimum thickness of  $10~\mu m$  has been measured with optical profilometry (Zygo NewView 7300 Optical Profilometer). An extra layer of PDMS is spun-coated on the GaIn alloy and cured (ii) before patterning the alloy and underlying PDMS substrate with a  $CO_2$  laser (iii). This extra layer of PDMS serves to prevent the



**Figure 3.** a) Test sample of a single layer of cPDMS patterned with a 0.6 W laser power. b) Test sample of a double-layer cPDMS patterned with 1.2 W. c) Patterned carbon-based cPDMS with a minimum line-to-line spacing of 260  $\mu$ m. d) Patterned silver-based cPDMS.

EGaIn from oxidizing and getting coated in debris during laser-patterning. Next, we remove the excess material (iv) and seal the patterned circuit (v). After the sealing layer has cured, we peel the circuit from the brass cutting sheet (vi). This approach to EGaIn patterning exploits the alloy's liquid state and strong surface tension, which allows it to hold its shape after being cut with a CO<sub>2</sub> laser. The samples presented in **Figures 5**a–e demonstrate the versatility of this approach to rapidly pattern liquid GaIn with millimeter-scale resolution over a large area. Figure 5f presents an integrated circuit composed of laser-patterned EGaIn and conductive elastomer electrodes (NuSil R-2637) used to mount an LED and connect the circuit to an external power supply. This sample demonstrates the ability to pattern multiple conductive materials and maintain conductivity.

#### 3. Discussion

We demonstrate that thin films of cPDMS and EGaIn can be patterned with a  $CO_2$  laser to produce intrinsically soft sensors and circuits that are elastically compatible with human skin. The steps presented in Figures 2 require a relatively inexpensive commercial laser engraving system and can be performed in minutes. As with other polymers and elastomers, we expect that the cPDMS is patterned through a combination of photothermal ablation and liquid expulsion. However, the ability to pattern EGaIn with a  $CO_2$  laser is surprising since GaIn is a metal alloy that does not ablate at  $10.6~\mu m$  and will not vaporize at  $1{\text -}30$  W to produce the vapor recoil force necessary for liquid expulsion. Instead, we postulate that the EGaIn is displaced by the recoil force of the PDMS vapor generated below the liquid metal film.

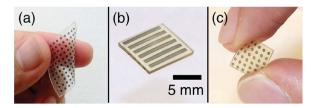


Figure 4. a) PDMS embedded with laser-patterned inclusions of PEDOT:PSS. b,c) Urethane embedded with laser-patterned PEDOT-PSS.

www.MaterialsViews.com

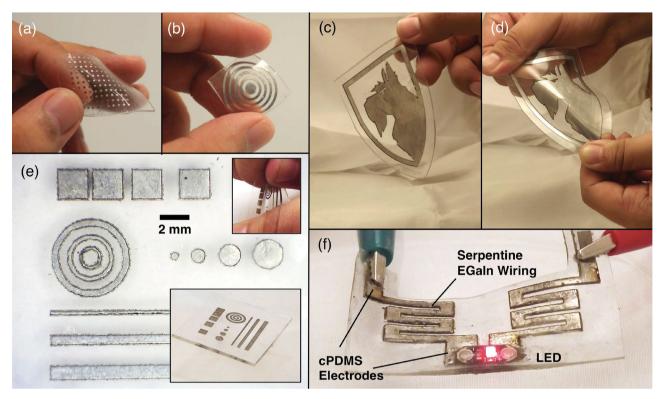
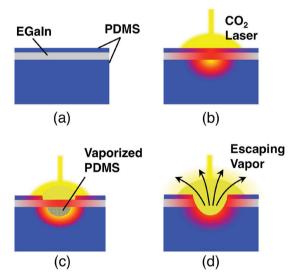


Figure 5. a,b) PDMS embedded with laser-patterned inclusions of EGaIn. c,d) Large area sample. e) Miniaturized features: 2 mm × 2 mm squares spaced 0.25, 0.5, and 1 mm apart; concentric rings with diameters of 1.5, 3, and 5 mm and widths of 0.25, 0.35, and 0.5 mm, respectively; circles with diameters of 0.5, 1, 1.5, and 2 mm; rectangular strips with widths of 0.3, 0.7, and 1 mm. f) LED circuit containing laser-patterned (Ag/Ni)cPDMS and EGaIn.



**Figure 6.** Proposed mechanism for expulsion of a thin film of liquid GaIn alloy on a PDMS substrate. a) The liquid alloy is coated with a thin layer of PDMS to prevent oxidation and limit exposure to debris. b) When exposed to the laser, the sample is locally heated and c) PDMS from the top and bottom layers vaporize. d) When the pressure difference between the vaporized polymer and atmosphere exceed the surface tension of the liquid film (including its  $Ga_2O_3$  skin), the vapor will puncture the liquid film and escape.

As illustrated in Figure 6a, the liquid alloy is deposited between two thin layers of PDMS. When exposed to the laser, the sample is locally heated (Figure 6b) and PDMS in the top and bottom layers is ablated (Figure 6c). We then postulate that the vaporized polymer exerts sufficient pressure on the EGaIn film to penetrate through and escape (Figure 6d). As in conventional laser beam welding (LBW), displacement occurs when the recoil force from this pressure exceeds the surface force supported by the surface tension  $\gamma_0$  and yield stress  $\tau_0$ of the liquid.[35] These values are estimated by pendant droplet measurements on EGaIn, which suggest  $\gamma_0 \approx 0.445$  J m<sup>-2</sup> and  $\tau_0 \approx 119 \text{ Pa.}^{[40]}$  Interestingly, pendant droplet experiments on Galinstan in pure nitrogen (<0.5 ppm O<sub>2</sub>) show greater surface tension (0.535 J m<sup>-2</sup>) than in an oxygenated (500 ppm O<sub>2</sub>) environment (0.510 J m<sup>-2</sup>).<sup>[39]</sup> In practice, the laser has a cutting radius of approximately  $r_c = 50 \mu m$ , which implies that the vaporized polymer exerts pressure on a circular region of GaIn with a circumference  $\eta = 2\pi r_c = 314 \ \mu m$ . For a film thickness  $h=10~\mu m$  and assuming  $\gamma_0 \approx 0.5~\mathrm{J~m^{-2}}$  the force required to puncture the oxide skin and displace the liquid alloy is approximately  $F = \eta(\gamma_0 + \tau_0 h) \approx 157 \mu N$ . This corresponds to a difference of 20 kPa between the local vapor pressure and the atmospheric pressure. For comparison, the recoil pressure of vapor under ambient conditions is estimated to be  $p_r \approx 0.55$  $p_s(T_s)$ , where  $p_s$  is the saturation vapor pressure and  $T_s$  is the surface temperature of the melting substrate.<sup>[41]</sup> An approxi-

www.afm-iournal.de

www.MaterialsViews.com

mate estimate for  $p_s$  is obtained from the Clausius-Clapeyron relation and Trouton's rule (valid for many organic liquids):  $\ln(p_s/p_{\rm atm}) \approx -10.6(T_{\rm v}/T_{\rm s}-1)$ , where  $p_{\rm atm}=101.3$  kPa is the atmospheric pressure and  $T_{\rm v}$  is the boiling point of the molten polymer.<sup>[42]</sup> Assuming  $T_{\rm v}=473$  K and a surface temperature  $T_{\rm s}=523$  °C, that is,  $T_{\rm s}$  the recoil pressure will be approximately 152 kPa, which corresponds to a pressure difference of 50.7 kPa exerted on the liquid alloy film. Another value for comparison is the direct radiation pressure exerted by the laser beam itself. For a maximum power of P=30 W, this is approximately  $p=nP/\pi c r_{\rm c}^2=24.1$  Pa, where n=1.89 is the refractive index of the  ${\rm Ga_2O_3}$  oxide surface  $^{[43]}$  and  $c=3\times 10^8$  m s $^{-1}$  is the speed of light. This is orders of magnitude less than the estimated pressure necessary to displace liquid GaIn and suggests that force from the beam alone is not sufficient for patterning.

Referring to Figure 3, linewidths of 118  $\mu m$  are accomplished with a cutting power of 0.6 W, PPI (pulses per inch) 1000, and speed 20%. Although not at the length scale necessary for microelectronics, 0.1–1 mm linewidths are adequate for a variety of sensing applications, including the contact detection sensors presented in Figure 1a,b. The sensor in Figure 1a consists of a central electrode and four surrounding electrodes. When the fingertip makes simultaneous contact between the inner circle and one of the outer triangles, an electrical connection is formed. Contact between different peripheral electrodes can be used to signal an "up", "down", "left", or "right" command. Similarly, for the sensor in Figure 1b, the location of the contacting fingertip can be determined by measuring the electrical resistance between electrode rows and columns at each node.

In this study, we have focused on elastically soft circuits with 0.1-1 mm linewidth circuit features that can be produced with a CO<sub>2</sub> laser. For microelectronics with 20-100 µm linewidths, a lower wavelength laser is required. The fundamental advantage of UV laser micromachining is the greater focal depth (b), and hence cutting depth, that can be achieved for a prescribed beam diameter (i.e., "waist size,"  $W_0$ ). The VLS 3.50 CO<sub>2</sub> laser engraver used for fabricating these devices has a beam diameter of 100  $\mu$ m.<sup>[44]</sup> For a Gaussian beam,  $b = 2\pi W_0^2/\lambda$ , where  $W_0$  is the minimum diameter of the beam ("waist size") and  $\lambda$ is the wavelength of the laser. [45] This implies that, in theory, a 355 nm Nd:YAG laser should have on the order of  $30\times$  the cutting depth of a 10.6 µm CO2 laser. Also, the lower wavelength of a UV laser allows for a much higher pulse rate (e.g., ≈100 kHz). This prevents heat from accumulating outside of the beam path, which would lead to melting and burning in the surrounding material and hence result in wider cuts.

## 4. Conclusions

Using a commercial  $30~W~CO_2$  laser, we are able to rapidly produce elastically soft electronic circuits composed of patterned cPDMS, PEDOT:PSS, and liquid-phase EGaIn alloy embedded in a thin film of PDMS. These circuits contain features with 0.1-1~mm linewidths and function as elastically stretchable wiring and sensors for measuring stretch, surface pressure, and friction. In the case of EGaIn, we postulate that patterning is accomplished with a mechanism that is analogous to the

liquid expulsion that occurs in high power (> 1 kW) laser beam welding (LBW). However, in contrast to LBW, recoil force does not come from the vaporized metal but is instead produced by vaporization of the underlying elastomer substrate. Moreover, because the liquid GaIn rapidly oxidizes in air, it forms a thin "oxide skin" that allows the patterned film to hold its shape after laser cutting and during sealing.

Future efforts will focus on further miniaturization with a commercial UV laser. We expect that the smaller beam size (≈15 µm) and higher pulse rate (≈100 kHz) will allow for linewidths as small as 20 µm. We also expect that at UV wavelengths (e.g.,  $\lambda = 355$  nm), the EGaIn can be patterned with photochemical ablation. This will eliminate the need to rely on the liquid expulsion mechanism presented in Figure 6 and instead allows the liquid alloy to be patterned on any substrate, including metal. UV laser machining will also allow us to pattern thin films of metal-based cPDMS without burning. As with EGaIn, we expect that silver microparticles will vaporize through photochemical ablation when excited with  $\lambda = 355$  nm radiation. Ultimately, we hope to have a universal protocol for using commercial laser micromachining to rapidly produce soft-matter electronics and hence eliminate the need for customized hardware or cleanroom fabrication.

## 5. Experimental Section

Fabrication of Laser-Patterned Carbon-Filled cPDMS Circuits: The carbon-filled cPDMS is made by mixing PDMS (Sylgard 184, Dow Corning, Inc.), acetylene carbon black powder (SigmaAldrich, Inc.) and hexane (SigmaAldrich, Inc) using a magnetic stir bar (Fisher Scientific, Inc.) to help disperse the mixture. The mixing ratio of PDMS is 20:1. The contents of carbon black, PDMS, and hexane are 8% wt, 42% wt, and 50% wt, respectively. First, conductive PDMS is spun coated on a piece of brass cutting surface. The spin coating includes two stages: in stage one and two, the spinning speeds are 700 and 2000 rpm, with corresponding durations of 9 and 25 s. After spin coating, the brass sheet is placed on a hot plate at 130 °C for 10 min to cure. Next, a laser engraver (VLS3.50; Universal Laser System, Inc.) is used to pattern the cPDMS. The settings are power of 0.6 W, 5% speed, and 1000 PPI. The patterning is repeated three times to make sure the cuts are all the way through and clean. The excess cPDMS is then manually removed with tweezers. After laser-patterning, PDMS (Sylgard 184; Dow Corning, Inc) with a base to crosslinking ratio of 10:1 is used to seal the circuit. The thickness of sealing layer can be determined by adjusting the settings of spin coating. Finally, the sealed circuit is peeled from the brass surface after curing at the same settings.

Fabrication of Laser-Patterned Silver-Filled cPDMS Circuits: Silver-filled cPDMS is made by mixing silver powder (Sigma-Aldrich, Inc.), PDMS (10:1 mixing ratio), and hexane (Sigma-Aldrich, Inc.) in a ratio of 42:8:50 with a sonicator (Branson, Inc.) for 10 min. A thin film applicator (ZUA 2000; Zehntner Testing Instruments) is used to apply the layer. The thickness is set to be 500 μm. After curing at 130 °C for 10 min, the film is laser-patterned with 3 W, 10% speed, and 1000 PPI. The remainder of the fabrication is identical to that of carbon filled cPDMS.

Fabrication of Laser-Patterned PEDOT:PSS: First a layer of PDMS is spun coat onto brass cutting surface at 1700 rpm for 5 s then cured. Next, PEDOT:PSS (662501, Sigma-Aldrich, Inc) is spun coat onto the PDMS at 400 rpm for 5 s and cured at 90 °C for 20 min and laser-patterned with power of 0.6 W, 5% speed, and 1000 PPI. The laser patterning is repeated twice. After removing the excess PDMS and PEDOT:PSS, the patterns are sealed with PDMS and the circuit is obtained. For PEDOT:PSS in urethane, we begin by spraying a mold release agent (Ease Release 200, Mann Release Technologies, Inc.)

www.afm-iournal.de

onto the brass cutting surface. Next, PEDOT:PSS is spun coat onto the brass cutting surface at 400 rpm for 5 s and cured at 90 °C for 20 min. Urethane (Ure-Bond, SmoothOn, Inc.) then is spun coat onto PEDOT:PSS at 1700 for 10 s and heated at 60 °C for 10 min. After curing, the urethane and PEDOT:PSS are laser-patterned twice with power of 0.9 W, speed 5%, and PPI 1000. Lastly, the patterns are sealed with Urethane and cured.

Fabrication of Laser-Patterned EGain Circuits: First a thin film of PDMS is applied to a brass cutting surface by spin coating at 1000 rpm for 10 s. After curing at 130 °C for 10 min, we deposit a thin film of EGaIn alloy on the PDMS film using an elastomeric roller. Another layer of PDMS is spun-coated onto the EGaIn at 700 rpm for 9 s and 1700 rpm for 5 s. The PDMS with EGaIn is laser-patterned with power of 0.6 W, speed 5%, and PPI 1000. This process is then repeated three times. Lastly, the excess material is removed and the circuit is completed with a sealing layer of PDMS. For the combined LED-EGaIn-cPDMS circuit, we first pattern NuSil R-2637 conductive elastomer to make the electrode pads for mounting the LED and connecting an external power supply. The cPDMS pads are sealed with non-conductive PDMS. After curing, the sample is turned over and coated with EGaIn. Another layer of PDMS is spun-coated on top of the EGaIn and cured. EGaIn is placed to partially overlap the electrode pads in order to establish an electrical connection. After the EGaIn is patterned, the excess material and the LED is mounted to the electrode pads. Lastly, the circuit is sealed in an addition layer of PDMS.

## **Acknowledgements**

This work was supported by a Defense Advanced Research Projects Agency (DARPA) Young Faculty Award (YFA).

> Received: November 3, 2013 Revised: December 3, 2013 Published online: February 21, 2014

- [1] M. Kaltenbrunner, G. Kettlegruber, C. Siket, R. Schwödiauer, Siegfried Bauer, Adv. Mater. 2010, 22, 2065.
- [2] T. Sekitani, Y. Noguchi, K. Hata, T. Fukushima, T. Aida, T. Someya, Science 2008, 321, 1468.
- [3] T. Yamada, Y. Hayamizu, Y. Yamamoto, Y. Yomogida, A. Izadi-Najafabadi, D. N. Futaba, K. Hata, Nat. Nanotechnol. 2011,
- [4] K. Y. Chun, Y. Oh, J. Rho, J.-H. Ahn, Y.-J. Kim, H. R. Choi, S. Baik, Nat. Nanotechnol. 2010, 5, 853.
- [5] X. Niu, S. Peng, L. Liu, W. Wen, P. Sheng, Adv. Mater. 2007, 19,
- [6] H. Cong, T. Pan, Adv. Funct. Mater. 2008, 18, 1912.
- [7] Q. Cao, J. A. Rogers, Adv. Mater. 2009, 21, 29.
- [8] D. J. Lipomi, M. Vosgueritchian, B. C.-K. Tee, S. L. Hellstrom, J. A. Lee, C. H. Fox, Z. Bao, Nat. Nanotechnol. 2011, 6, 788.
- [9] K. S. Kim, Y. Zhao, H. Jang, S. Y. Lee, J. M. Kim, K. S. Kim, J.-H. Ahn, P. Kim, J.-Y. Choi, B. H. Hong, Nature 2009, 457, 706.
- [10] J. A. Rogers, T. Someya, Y. Huang, Science 2010, 327, 1603.
- [11] S. Lacour, S. Wagner, Z. Huang, Z. Suo, Appl. Phys Lett. 2003, 82,

- [12] S. Zhu, J.-H. So, R. Mays, S. Desai, W. R. Barnes, B. Pourdeyhimi, M. D. Dickey, Adv. Funct. Mater. 2013, 23, 2308.
- [13] H. J. Kim, C. Son, B. Ziaie, Appl. Phys Lett. 2008, 92, 011904.
- [14] J. H. So, J. Thelen, A. Qusba, G. J. Hayes, G. Lazzi, M. D. Dickey, Adv. Funct. Mater. 2009, 19, 3632.
- [15] S. Cheng, Z. Wu, P. Hallbjorner, K. Hjort, A. Rydberg, IEEE T. Antenn. Propag. 2009, 57, 3765.
- [16] S. Cheng, Z. Wu, Adv. Funct. Mater. 2011, 21, 2282.
- [17] H.J. Koo, J.-H. So, M. D. Dickey, O. D. Velev, Adv. Mater. 2011, 23, 3559.
- [18] J. H. So, H.-J. Koo, M. D. Dickey, O. D. Velev, Adv. Funct. Mater. 2012, 22, 625.
- [19] C. Majidi, Y.-L. Park, R. Kramer, P. Bérard, R. J. Wood, J. Micromech. Microeng. 2010, 20, 125029.
- [20] R. D. P. Wong, J. D. Posner, V. J. Santos, Sensor. Actuat. A-Phys. 2012, 179, 62.
- [21] Y. L. Park, B. R. Chen, R. J. Wood, IEEE Sens. J. 2012, 12, 2711.
- [22] P. Roberts, D. D. Damian, W. Shan, T. Lu, C. Majidi, in Proc. of the IEEE Conf. Robotics Automation 2013, 3529.
- [23] D. M. Vogt, Y.-L. Park, R. J. Wood, IEEE Sens. J. 2013, 13, 4056.
- [24] C. Majidi, R. Kramer, R. J. Wood, Smart Mater. Struct. 2011, 20, 105017.
- [25] J. M. Engel, N. Chen, K. Ryu, S. Pandya, C. Tucker, Y. Yang, C. Liu, presented at 12th Hilton Head Wksp., Hilton Head Island, SC 2006.
- [26] C.X. Liu, J.W. Choi, Microsyst. Technol. 2012, 18, 365.
- [27] C.X. Liu, J.W. Choi, J. Micromech. Microeng. 2009, 19, 085019.
- [28] C. Ladd, J.H. So, J. Muth, M. D. Dickey, Adv. Mater. 2013, 25, 5081.
- [29] R. K. Kramer, C. Majidi, R. J. Wood, Adv. Funct. Mater. 2013, 23,
- [30] A. Tabatabai, A. Fassler, C. Usiak, C. Majidi, Langmuir 2013, 29, 6194
- [31] S. H. Jeong, A. Hagman, K. Hjort, M. Jobs, J. Sundqvist, Z. Wu, Lab Chip 2012, 12, 4657.
- [32] W. Shan, T. Lu, C. Majidi, Smart Mater. Struct. 2013, 22, 085005.
- [33] H. Klank, J. P. Kutter, O. Geschke, Lab Chip 2002, 2, 242.
- [34] B. A. Fogarty, K. E. Heppert, T. J. Cory, K. R. Hulbutta, R. S. Martin, S. M. Lunte, Analyst 2005, 130, 924.
- [35] S. Basu, T. DebRoy, J. Appl. Phys. 1992, 72, 3317.
- [36] R. C. Chiechi, E. A. Weiss, M. D. Dickey, G. M. Whitesides, Angew. Chem. 2007, 120, 148.
- [37] M. D. Dickey, R. C. Chiechi, R. J. Larsen, E. A. Weiss, D. A. Weitz, G. M. Whitesides, Adv. Funct. Mater. 2008, 18, 1097.
- [38] S. Cheng, Z. Wu, Lab Chip 2012, 12, 2782.
- [39] T. Liu, P. Sen, C. J. Kim, J. Microelectromech. Syst. 2012, 21, 443.
- [40] Q. Xu, N. Oudalov, Q. Guo, H. M. Jaeger, E. Brown, Phys. Fluids **2012**, 24, 063101.
- [41] V. Semak, A. Matsunawa, J. Phys. D Appl. Phys. 1997, 30, 2541.
- [42] D. Mackay, A. Bobra, D. W. Chan, W. Y. Shiu, Environ. Sci. Technol. **1982**, 16, 645.
- [43] M. Rebien, W. Henrion, M. Hong, J. P. Mannaerts, M. Fleischer, Appl. Phys. Lett. 2002, 81, 250.
- [44] A. Toossi, M. Daneshmand, D. Sameoto, J. Micromech. Microeng. **2013**, 23, 047001.
- [45] J. Vasco, P. J. Bartolo, B. Silva, C. Galo, Assembly Autom. 2007, 27,